

WEST**Freeform Search**

Database:

US Patents Full-Text Database
 US Pre-Grant Publication Full-Text Database
JPO Abstracts Database
 EPO Abstracts Database
 Derwent World Patents Index
 IBM Technical Disclosure Bulletins

Term:

(CVD or plasma) and apparatus and (clean\$3 with
gas\$3)

Display: **Documents in Display Format:** **Starting with Number:**

Generate: Hit List Hit Count Image

Search History

Today's Date: 5/31/2001

<u>DB Name</u>	<u>Query</u>	<u>Hit Count</u>	<u>Set Name</u>
JPAB,EPAB,DWPI,TDBD	(CVD or plasma) and apparatus and (clean\$3 with gas\$3)	617	<u>L7</u>
USPT	((118/723R)!.CCLS.)	412	<u>L6</u>
USPT	((118 723MP)!.CCLS.)	182	<u>L5</u>
USPT	((118 726)!.CCLS.)	956	<u>L4</u>
USPT	L2 and (clean\$3 with fluoride)	26	<u>L3</u>
USPT	L1 and (clean\$3 with gas\$3)	264	<u>L2</u>
USPT	((118 726 (118/723R (118/723MP (118/723ME (118 723MR 118/723MA 118/723E)!.CCLS.)	2271	<u>L1</u>